

U. S. DEPARTMENT OF COMMERCE
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LIST OF REFERENCES CITED BY APPLICANT(S)
(Use several sheets if necessary.)

APPLICANT

HIBOKATSU MIYATA ET AL

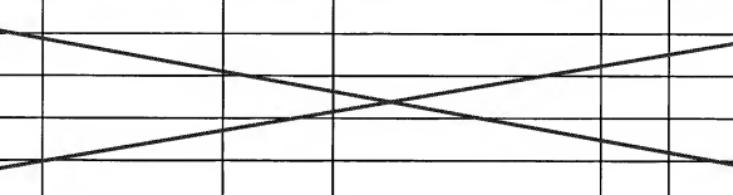
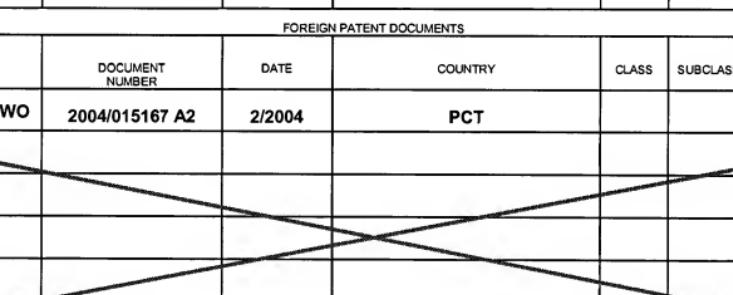
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U.S. PATENT DOCUMENTS

U.S. PATENT DOCUMENTS						
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	2003/0012931 A1	1-2003	Kuroda et al.	428	188	1/7/2000
						
FOREIGN PATENT DOCUMENTS						
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT
WO	2004/015167 A2	2/2004	PCT			
						
OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)						
	Besson et al., "A New 3D Organization of Mesopores in Oriented CTAB Silica Films", J. Phys. Chem. B 2000, 104, 12095-12097, XP-002304393					
	Grosso et al., "Highly oriented 3D-hexagonal silica bromide", J. Mater. Chem., Vol. 10, No. 9, pp. 2085-2089 (2000)					
	Patent Abstracts of Japan, Vol. 2003, No. 3 (2003)					

***EXAMINER:** Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /AD/

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